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12/06/01

PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10003288	FILING DATE 12/06/2001	CLASS 430	SUBCLASS 270.1	GAU 1756	EXAMINER LEE, S.S.
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\*\*APPLICANTS: Hatakeyama Jun; Kobayashi Tomohiro; Watanabe Takeru;

\*\*CONTINUING DATA VERIFIED:

\*\* FOREIGN APPLICATIONS VERIFIED:

JAPAN 2000-373316 12/07/2000

PG-PUB DO NOT PUBLISH ☐

RESCIND ☐

Foreign priority claimed ☐ yes ☐ no

35 USC 119 conditions met ☐ yes ☐ no

Verified and Acknowledged Examiners's initials

ATTORNEY DOCKET NO

KOJIM-440

TITLE : Amine compounds, resist compositions and patterning process

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
		Total Claims	Print Claim for O.G.
<b>ISSUE FEE</b>		<b>DRAWING</b>	
Amount Due	Date Paid	Sheets Drawn	Figs. Drawn
		Print Fig.	
<input type="checkbox"/> <b>TERMINAL</b>		<b>PREPARED FOR ISSUE</b>	
<b>DISCLAIMER</b>		<p><b>WARNING:</b> The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368. Possession outside the U.S. Patent &amp; Trademark Office is restricted to authorized employees and contractors only.</p>	

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